Background Techniques

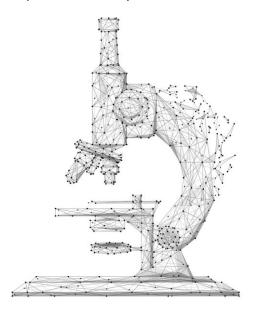
Nanoanalytics Lab Opening

Presentations of the latest XPS, TOF-SIMS and AFM-IR / sSNOM Instruments at the Institute of Physics, Universität der Bundeswehr

Date May 8th, 2018

Location Universität der Bundeswehr, Werner-Heisenberg-Weg 39, 85577 Neubiberg; Institute of Physics

Hosted by Universität der Bundeswehr in Cooperation with Physical Electronics GmbH





The Institute of Physics of the Universität der Bundeswehr München has an analysis and research laboratory that is unparalleled. With two new acquisitions of the VersaProbe III and the nanoIR2-s from Anasys Instruments, the surface analysis laboratory has now been completed.

Prof. Georg S. Düsberg holds the Chair of Sensor Technologies at the Institute of Physics of the Universität der Bundeswehr in Munich since January 2017. Since that time he is responsible for a lot of new equipment acquisitions for the Nanoanalytics Lab, in addition to the already existing capabilities. Prof. Düsberg's research covers material synthesis and analytics at the nanoscale including materials such as carbon nanotubes, graphene and other 2D films.

In addition to the nanoTOF II, a TOF-SIMS also from Physical Electronics, the VersaProbe III, the latest XPS system from Physical Electronics equipped with UPS, will soon provide unique results in the development of novel components with low-dimensional materials.

The Institute of Physics also procured the nanoIR2-s from Anasys Instruments. The nanoIR2-s is a combination of AFM, IR spectroscopy plus scattering SNOM, which means 3 technologies in one. Scattering SNOM provides information about the complex optical properties of the nano-scale region of the sample under a metallized tip.

PHI VersaProbe III



XPS the surface sensitive technique can generally obtain information on elements within a few nms of the sample surface.

nanolR2-s



nanoIR2-s united two complementary nanoscale IR techniques, s-SNOM and AFM-IR. This combination creates remarkable new data and elimates the need for complex optical alignments..

PHI nanoTOF II



Identifying elements and molecular fragments with the nanoTOF II. PHI'S patented TRIFT mass spectrometer provides superior sensitivity, low spectral background and the unique ability to image highly topographic surfaces.

Agenda

Registration

Date, Signature



Prof. Dr. Georg Düsberg Chair of Sensor Technologies Universität der Bundeswehr

Organizing Committee Members & Speakers



Stefanie Zauzig
Organization & Marketing
PHI GmbH

Speakers



Dr. Greg Fisher TOF-SIMS PHI USA



Dr. Andrey Lyapin XPS PHI GmbH



Dr. Miriam Unger AFM-IR + sSNOM Anasys Instruments

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